

240 County Road Ipswich, MA 01938-2723 Tel 978-927-5054 Fax 978-921-1350 www.neb.com info@neb.com

New England Biolabs Certificate of Analysis

Product Name: PhiX174 RF II DNA

Catalog Number: N3022L
Concentration: 1,000 µg/ml

Unit Definition: N/A

Packaging Lot Number: 10185535 Expiration Date: 03/2025 Storage Temperature: -20°C

Storage Conditions: 10 mM Tris-HCl (pH 8.0), 1 mM EDTA

Specification Version: PS-N3022S/L v1.0

PhiX174 RF II DNA Component List				
NEB Part Number	Component Description	Lot Number	Individual QC Result	
N3022LVIAL	PhiX174 RF II DNA	10184496	Pass	

Assay Name/Specification	Lot # 10185535
A260/A280 Assay The ratio of UV absorption of φX174 RF II DNA at 260 and 280 nm is between 1.8 and 2.0.	Pass
DNA Concentration (A260) The concentration of φX174 RF II DNA is between 1000 and 1050 μg/ml as determined by UV absorption at 260 nm.	Pass
Electrophoretic Pattern (Plasmid) The banding pattern of φX174 RF II DNA on a 1.2% agarose gel is evaluated against a control lot for sharpness and relative intensity as determined by gel electrophoresis using Ethidium Bromide.	Pass
Non-Specific DNase Activity (DNA, 16 hour) A 50 μl reaction in 1X NEBuffer 2 containing 5 μg of φX174 RF II DNA incubated for 16 hours at 37°C results in a DNA pattern free of detectable nuclease degradation as determined by agarose gel electrophoresis.	Pass
Restriction Digest (Linearization) A 50 μl reaction in CutSmart™ Buffer containing 5 μg of φX174 RF II DNA DNA and 20 units of XhoI incubated for 1 hour at 37°C produces > 95% linearization resulting in a single band of approximately 5386 bp as determined by agarose gel electrophoresis.	Pass



N3022L / Lot: 10185535

Page 1 of 2



This product has been tested and shown to be in compliance with all specifications.

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Vanessa Mathieu-Sheltry Production Scientist

23 Mar 2023

Michael Tonello

Packaging Quality Control Inspector

24 Apr 2023